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U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10079289	FILING DATE 02/19/2002	CLASS 430	SUBCLASS	GAU 1752	EXAMINER
**APPLICANTS: Sooriyakumaran Ratnam; Allen Robert; Fenzel-Alexander Debra;					
**CONTINUING DATA VERIFIED: THIS APPLICATION IS A CIP OF 09/748,071 12/21/2000					
** FOREIGN APPLICATIONS VERIFIED:					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO YOR920000693US2	
Verified and Acknowledged Examiners's initials					
TITLE : Substantially transparent aqueous base soluble polymer system for use in 157 nm resist applications					

U.S. DEPT. OF COM. / PAT. & TM-PTO-436 (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	
		Print Claim for O.G.	
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Fig. Drwg.
		Print Fig.	
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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